

## SBR05U20LPS-p SBR07U20LPS-p

## Part Number: SBR DFN1006H4-2 Package Weight (mg): 0.7994

## p = package designator See Data Sheet

Element	Material Group	Materials	CAS (if applicable)	Average mass homogeneous Materal(%)		Mass (mg)	ppm Homogeneous Material	ppm overall
Chip	Silicon w/Metal	Doped Silicon*	7440-21-3	100.00%	3.77	0.0301	1000000	37653
Leadframe	C7025	Cu	7440-50-8	95.90%	44.86	0.3586	959000	430194
		Si	7440-21-3	0.73%			7250	3252
		Ni	7440-02-0	3.20%			32000	14355
		Mg	7439-95-4	0.18%			1750	785
Leadframe Plating	Intenal plating	Ni	7440-02-0	100.00%	1.04	0.0083	1000000	10383
	middle plating	Pd	2023568	100.00%	0.10	0.0008	1000000	1001
	outer plating	Au	7440-57-5	100.00%	0.01	0.0001	1000000	125
Bond Wire	Gold Wire	Gold	7440-57-5	100.00%	2.94	0.0235	1000000	29397
Encapsulation	EME-G770HCD	Silica fused	60676-86-0	93.50%	45.33	0.3624	935000	423873
		Epoxy resin		3.00%			30000	13600
		Phenol resin		3.00%			30000	13600
		Carbon Black	1333-86-4	0.50%			5000	2267
Die Attach Epoxy	QMI519	Ag	7440-22-4	80.00%	1.95	0.0156	800000	15612
		palladium compound		0.15%			1500	29
		2,6-Di-tert-butyl-p-cresol	128-37-0	0.01%			50	1
		Hydroquinone	123-31-9	0.00%			1	0
		Acrylate		15.84%			158449	3092
		Bismaleimide resin		3.00%			30000	585
		Polymer of polybutadiene and anlydride		1.00%			10000	195
				Total	100.00	0.7994		1000000

Tolerance ±10%

This data is based on information provided by our suppliers. We believe it to be correct but do not routinely validate it by measurement. It is for guidance only and Diodes Inc. does not guarantee its absolute accuracy or completeness

\* The Silicon Chip is doped at atomic levels with trace amounts of elements that may include Phosphorus, Boron, Arsenic, and other elements. Metalization may include Titanium, Nickel, Aluminum, Silver or Gold These substances are not reported where their concentration is less than the minimum reportable level per the guidelines specified in the Tables of EIA JIG-101, *Material Composition Declaration for Electronic Products*.

This product or product family does not contain any of the following substances except as CURRENTLY exempted by ELV II and RoHS and reported above: Organic tin compounds

Asbestos Antimony Compounds Azo compounds Cadmium and cadmium compounds Certain Shortchain Chlorinated Paraffins Chlorinated organic compounds Dimethyl fumarate Halogens Hexavalent chromium compounds Lead and lead compounds Mercury and mercury compounds

REACH SVHCs and other Substances of Concern: Anthracene 4,4'- Diaminodiphenylmethane Dibutyl phthalate Cyclododecane Cobalt dichloride Diarsenic pentaoxide Diarsenic trioxide Sodium dichromate, dihydrate

Beryllium, Beryllium Alloys and Compounds Hydrazine Tetrachloroethylene Toluene Toluene Diisocyanate Ozone Depleting Substances - Class I (CFCs, HBFCs, etc.) Ozone Depleting Substances - Class II (HCFCs) Perfluoroctane Sulphonate (PFOS) or related compounds Polybrominated biphenyls (PBB) and Polybrominated diphenyl ethers (PBDE) including DecaBDE Polychlorinated Biphenyls (PCBs) Polychlorinated Apphthalenes ( > 3 chlorine atoms) Radioactive Substances Red Phosphorous Tributyl Tin (TBT) and Triphenyl Tin (TPT) Tributyl Tin Oxide (TBTO)

5-tert-butyl-2,4,6-trinitro-m-xylene (musk xylene) Bis (2-ethyl(hexyl)phthalate) (DEHP) Hexabromocyclododecane (HBCDD) Alkanes, C10-13, chloro (Short Chain Chlorinated Paraffins) Bis(tributyltin)oxide Lead hydrogen arsenate Triethyl arsenate Benzyl butyl phthalate

Methylene Chloride Trichloroethene Methyl Ethyl Ketone Xylenes